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P2002,1010

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I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 or facsimile transmitted to the U.S. Patent and Trademark Office on the date shown below.


SignatureApril 24, 2006
DateIN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applic. No. : 10/723,631 Confirmation No. 9710
Applicant : Frank-Michael Kamm
Filed : November 26, 2003
Title : REFLECTION MASK FOR PROJECTING A STRUCTURE
ONTO A SEMICONDUCTOR WAFER AND METHOD FOR
PRODUCING THE MASK
Group Art Unit : 1756
Examiner : Stephen D. Rosasco
Docket No. : P2002,1010
Customer No. : 24131

R E S P O N S E

Mail Stop Amendment
Hon. Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

S i r :

Responsive to the Office Action dated November 22, 2005,
kindly consider the following:

Remarks/Arguments begin on page 2 of this paper.

04/25/2006 TL0111 00000019 10723631

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